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APPLICATION N	O. I	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/053,572		01/24/2002	Hideto Ohnuma	740756-2422	740756-2422 3447	
31780	7590	01/18/2005		EXAMINER		
	DBINSON		KENNEDY, JENNIFER M			
PMB 955 21010 SO	UTHBANK	ST.		ART UNIT	PAPER NUMBER	
POTOMA	POTOMAC FALLS, VA 20165			2812		
				DATE MAILED: 01/18/2005		

Please find below and/or attached an Office communication concerning this application or proceeding.

			A
	Application No.	Applicant(s)	7110
Advisory Action	10/053,572	OHNUMA, HIDETO	
•	Examiner	Art Unit	
	Jennifer M. Kennedy	2812	
The MAILING DATE of this communication app	pears on the cover sheet with the	correspondence address	
THE REPLY FILED FAILS TO PLACE THIS AF Therefore, further action by the applicant is required to final rejection under 37 CFR 1.113 may only be either: condition for allowance; (2) a timely filed Notice of App Examination (RCE) in compliance with 37 CFR 1.114.	(1) a timely filed amendment wh	cation. A proper reply to ich places the applicatio	n in
PERIOD FOR F	REPLY [check either a) or b)]		
a) The period for reply expires 3 months from the mailing date b) The period for reply expires on: (1) the mailing date of this A event, however, will the statutory period for reply expire later ONLY CHECK THIS BOX WHEN THE FIRST REPLY WA 706.07(f). Extensions of time may be obtained under 37 CFR 1.136(a). The nave been filled is the date for purposes of determining the period of extensions of the shorten (b) above, if checked. Any reply received by the Office later than three rearned patent term adjustment. See 37 CFR 1.704(b).	dvisory Action, or (2) the date set forth in the than SIX MONTHS from the mailing date of SILED WITHIN TWO MONTHS OF THE date on which the petition under 37 CFR 1. ension and the corresponding amount of the datatutory period for reply originally set in	of the final rejection. IE FINAL REJECTION. See M 136(a) and the appropriate exte e fee. The appropriate extensio the final Office action; or (2) as	PEP nsion fee n fee under s set forth in
1. A Notice of Appeal was filed on Appellar 37 CFR 1.192(a), or any extension thereof (37 CFR)		-	
2. The proposed amendment(s) will not be entered	because:		
(a) they raise new issues that would require fur	ther consideration and/or search	(see NOTE below);	
(b) They raise the issue of new matter (see Note	e below);		
(c) they are not deemed to place the application issues for appeal; and/or	n in better form for appeal by ma	terially reducing or simp	lifying the
(d) they present additional claims without cand NOTE:	eling a corresponding number of	finally rejected claims.	
3. Applicant's reply has overcome the following rej	ection(s):		
Newly proposed or amended claim(s) wou canceling the non-allowable claim(s).		separate, timely filed am	nendment
5. ☐ The a) ☐ affidavit, b) ☐ exhibit, or c) ☐ request application in condition for allowance because:		sidered but does NOT p	lace the
6. The affidavit or exhibit will NOT be considered by raised by the Examiner in the final rejection.	pecause it is not directed SOLELY	to issues which were n	ewly
7. For purposes of Appeal, the proposed amendme explanation of how the new or amended claims	· / / ==	•	an
The status of the claim(s) is (or will be) as follow	s:		
Claim(s) allowed:			
Claim(s) objected to:	√		
Claim(s) rejected: <u>1-36</u> .			
Claim(s) withdrawn from consideration:		•	
8. The drawing correction filed on is a) a	pproved or b) disapproved by	the Examiner.	
9. Note the attached Information Disclosure Statem	nent(s)(PTO-1449) Paper No(s).	·	
10. Other:		Jeuns Macus Jennifer M. Kennedy Patent Examiner Art Unit: 2812	ed g

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Application/Control Number: 10/053,572

Art Unit: 2812

Applicant argues examiner's motivation for combining. The examiner maintains that the three criteria for establishing a prima facie case of obviousness has been meet.

First, the examiner has provided a suggestion or motivation to combine from the references themselves. The examiner maintains that it would have been obvious to form the oxide film of Zhang et al. by the method of Ohtani et al. since the examiner notes that Zhang et al. does not disclose a particular method for forming the oxide layer 33, and therefore the particular method used to form the oxide layer lacks criticality in the invention of Zhang et al. One of ordinary skill in the art at the time the invention was made would have recognized that any known method could be used to form the oxide layer 33 in the absence of a particular suggestion by Zhang et al. Ohtani et al. discloses a method of forming a chemical oxide film (see column 2, lines 44-46, and column 6, lines 55-64). Thus, it would have been obvious to one of ordinary skill in the art at the time the invention was made to form the oxide layer of Zhang et al. by the method of Ohtani et al., since the method of forming an oxide layer lacks criticality in the invention of Zhang et al., and since the method of Ohtani is a known method of forming an oxide that improves the surface characteristics of the underlying film (see Ohtani et al. column 2, lines 39-46).

Applicant argues that the fact that there is no method for forming the oxide layer disclosed in Zhang does not mean that any known method could be used to form the oxide layer. The examiner maintains that because Zhang et al. does not disclose a particular method for forming the oxide layer 33 the particular method used to form the oxide layer lacks criticality in the invention of Zhang et al. and that one of ordinary skill

Application/Control Number: 10/053,572

Art Unit: 2812

in the art at the time the invention was made would have recognized that any known method could be used to form the oxide layer 33 in the absence of a particular suggestion by Zhang et al. Nevertheless, the method of Ohtani et al. teaches a method that would have had the advantage of improved surface characteristics of the underlying amorphous silicon layer.

The fact that applicant has recognized another advantage which would flow naturally from following the suggestion of the prior art cannot be the basis for patentability when the differences would otherwise be obvious. See *Ex parte Obiaya*, 227 USPQ 58, 60 (Bd. Pat. App. & Inter. 1985).

Further, the examiner notes that the improved surface characteristics allow for a nickel catalyst to be used In Ohtani et al., which accelerates the crystallization of the amorphous film. The combination of Zhang et al. and Ohtani et al. have also been relied upon to show the limitations of a metal catalyst for crystallization of the amorphous silicon.

Second, there must be a reasonable expectation of success. Since it is clear that the method of Ohtani et al. would form an oxide there is an expectation of success in the method of Zhang, which requires an oxide.

Finally, the prior art reference (or references when combined) must teach or suggest all the claim limitations. The examiner maintains that all limitations have been met by the combination of the Zhang et al. and Ohtani et al. al. as evidenced by the item by item matching in the detailed rejection of the claims.